Silicon Photonics for Microwave Photonics Applications

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(Invited Paper)

Abstract—We provide an overview of recent work on developing integrated microwave photonic subsystems in silicon photonics for generating chirped microwave waveforms as well as for optical true time delay. First, we describe on-chip spectral shapers based on Bragg gratings (BGs), including a distributed Fabry-Pérot cavity, a Michelson interferometer incorporating identical chirped BGs, and a Sagnac loop incorporating a chirped BGs, for use in wavelength-to-time mapping systems. The performance of these on-chip spectral shapers is compared to those based on microring resonators as well as fiber or free-space configurations. Second, we consider the development of an index variable optical true time delay line (OTTDL) using subwavelength grating (SWG) waveguides. For SWG waveguides of the same length, incremental delays can be obtained by tailoring the group index via control over the duty cycle. We compare the performance of SWG waveguide OTTDLs to other length variable implementations in silicon.

Index Terms—Silicon photonics, microwave photonics, Bragg gratings, subwavelength grating waveguides, optical true time delay, photonic generation and processing of microwave signals

I. INTRODUCTION

Microwave photonics (MWP) unites the disciplines of microwave and optical engineering and focuses on the use of photonic techniques and technologies to generate, process, and analyze/characterize microwave signals [1-4]. By exploiting the capabilities of photonics for providing broad bandwidth, parallelization, and adaptiveness (e.g., to achieve readily reconfiguration and tuning), the value added of MWP is that it supports the realization of a number of important functions in microwave systems that are either too complex or not possible to implement with conventional electronic approaches.

Applications of MWP have evolved significantly since the early idea of using optical means to transport/distribute microwave signals over long distances and include, amongst others, broadband communications, sensing, and instrumentation. In support of these applications, a number of functions are required, including photonic generation of arbitrary waveforms, e.g., microwave, millimeter wave, and THz signals; photonic processing of microwave signals, e.g., filtering, time delay, and phase shifting; and photonic characterization of microwave signals, e.g., spectrum analysis and instantaneous frequency measurement (IFM).

In recent years, significant efforts have been directed on developing integrated photonic technologies to realize microwave photonic signal processing functions [5-10]. This has been motivated by the need to address outstanding issues of ‘bulk’ MWP systems and MWP signal processing engines, particularly the lack of compactness, stability, and reliability, as well as performance. To date, the main MWP integration platforms considered are silica, silicon nitride, silicon-on-insulator (SOI), InP, LiNbO₃, and chalcogenide glasses (see [6] for a review). Each presents advantages and/or strengths in terms of passive optical signal routing and processing, integration with (RF) electronics, light generation, and photodetection. Indeed, highly sophisticated (sub-)systems in InP [5], silicon nitride [7], and SOI [10] have been realized; moreover, nonlinear integrated microwave photonic circuits in chalcogenide to implement highly selective filters or to perform broadband IFM have been demonstrated [9].

In this paper, we discuss recent work on silicon photonics for microwave arbitrary waveform generation, such as chirped microwave waveforms, and microwave signal processing, specifically the implementation of broadband optical true time delay lines (OTTDLs). The remainder of this paper is organized as follows. In Section 2, we describe the photonic generation of chirped microwave waveforms based on spectral shaping and wavelength-to-time mapping (WTM). We review the development of on-chip spectral shapers based on waveguide Bragg gratings (BGs) and provide a comparison of such spectral shapers to those based on ring resonators and other fiber or free-space approaches. In Section 3, we present the use of subwavelength grating (SWG) waveguides as a means to realize index variable OTTDLs. The performance of these OTTDLs is compared to that of conventional length or wavelength variable optical delay lines (ODLs). Finally, conclusions and an outlook are given in Section 4.

II. GENERATION OF CHIRPED MICROWAVE AND MILLIMETER WAVE WAVEFORMS

A. General Overview

Microwave and millimeter wave waveforms are needed in broadband (wireless) communications as well as imaging and
impulse radar. In particular, chirped microwave and millimeter wave waveforms can be compressed in order to improve measurement resolution and increase detection distance in radar systems [11]. Characteristics of the waveforms include the central frequency, RF chirp, time bandwidth product [a large TBWP is needed to achieve a high pulse compression ratio], stability (e.g., pulse to pulse uniformity), and signal-to-noise ratio. We are particularly interested in the first three.

Photonic generation of microwave and millimeter wave waveforms can overcome limitations associated with electronic means, particularly with digital-to-analog converters. Over the years, many approaches for photonic generation of microwave and millimeter wave waveforms have been explored. The use of optical pulse shaping to synthesize a desired optical (temporal) waveform followed by photodetection is highly popular since it provides flexibility in terms of reconfiguration and tunability and indeed, a wealth of optical pulse shaping techniques are available [12]. In terms of ease of implementation, optical spectral shaping followed by WTM is very attractive [13-18]. A spectral shaper is used to tailor the amplitude spectrum of a pulsed broadband optical source and the shaped spectrum then propagates through a dispersive medium where the frequency content is distributed in the time domain, i.e., WTM, see Fig. 1.

A number of different techniques exist to characterize the generated chirped waveforms, including the use of a high-bandwidth photodiode and sampling oscilloscope (or a real-time oscilloscope) to visualize the time-domain waveform or an electrical (RF) spectrum analyzer for spectrum analysis. With an RF spectrum analyzer, only the power spectrum is typically available. On the other hand, the variation in the instantaneous frequency as a function of time can be obtained from the time-domain waveform through post processing, e.g., calculations using the Hilbert transform or spectrogram distributions. The results presented below are based on post processing calculations.

Fig. 1. Principle for photonic generation of chirped microwave waveforms based on optical spectral shaping and WTM.

Generating a uniform microwave waveform (constant frequency or chirp-free) requires a spectral shaper with a periodic filter response, i.e., constant free spectral range (FSR), and a linear WTM. To obtain a chirped waveform, two approaches can be adopted: (1) the use a spectral shaper with a constant FSR followed by a nonlinear WTM (e.g., [17]) or alternatively, (2) the use of a spectral shaper with a variable FSR followed by a linear WTM. In this paper, we focus on the latter, which avoids the lack of readily available integrated dispersive media with nonlinear delay. The key element in these waveform generation systems is the spectral shaper: it must allow for the synthesis of the desired amplitude spectrum which will ultimately correspond to the desired waveform after WTM.

In this section, we review different on-chip spectral shapers based on BGs, in particular the distributed Fabry-Pérot cavity (DFPC), a Michelson interferometer incorporating chirped Bragg gratings, and a Sagnac loop incorporating a chirped Bragg grating. We then compare the ability of these on-chip spectral shapers to generate chirped microwave waveforms with other integrated approaches such as ring resonators as well as fiber and free-space implementations.

A DFPC can be created using (linearly) chirped BGs that are spatially separate or overlapping (partially or fully) as shown schematically in Fig. 2 [19-21]. Such a DFPC has an FSR that is wavelength dependent [21]:

\[
FSR(\lambda) = \frac{\lambda_0^2}{2n_{\text{eff}} L(\lambda)} = \frac{\lambda_0^2}{2n_{\text{eff}} \left( L_{\text{offset}} + \frac{C_1 - C_2}{C_1 C_2} (\lambda - \lambda_0) \right)}
\]

where \( L(\lambda) \) represents the wavelength dependent, equivalent cavity length; \( n_{\text{eff}} \) is the effective index of the waveguide, \( C_1 \) and \( C_2 \) are the linear chirps of the gratings (in nm/mm or nm/cm), \( L_{\text{offset}} \) is the spatial offset between the gratings measured from the start of each grating, and \( \lambda_0 \) is the starting wavelength. After WTM in a dispersive medium with a first-order dispersion coefficient \( \Phi_0 \) (in units of ps/nm), the instantaneous frequency of the microwave waveform can be approximated by

\[
f_{RF}(t) \approx 2n_{\text{eff}} \left[ \frac{C_1 - C_2}{C_1 C_2} \left( \frac{t}{\lambda_0^2 \Phi_0^2} - \frac{1}{\lambda_0 \Phi_0} \right) + \frac{L_{\text{offset}}}{\lambda_0^2 \Phi_0} \right]
\]

and the corresponding RF chirp is

\[
\frac{df_{RF}(t)}{dt} = 2n_{\text{eff}} \left( \frac{C_1 - C_2}{C_1 C_2} \right) \frac{1}{\lambda_0^2 \Phi_0^2}
\]

We consider a fixed dispersive medium providing a fixed WTM. If the grating chirps are fixed, the central frequency \( f_{RF} \) and the corresponding RF chirp is

\[
\frac{df_{RF}(t)}{dt} = 2n_{\text{eff}} \left( \frac{C_1 - C_2}{C_1 C_2} \right) \frac{1}{\lambda_0^2 \Phi_0^2}
\]
of the waveform (i.e., at \( t = 0 \)) is determined by the amount of spatial offset \( L_{\text{offset}} \) between the two gratings. On the other hand, the RF chirp is independent of \( L_{\text{offset}} \) and depends only on the grating chrips.

Wang and Yao demonstrated an all-fiber DFPC based on two spatially separate identical linearly chirped fiber Bragg gratings with opposite orientation (i.e., \( L_{\text{offset}} > L_g \) where \( L_g \) is the length of the BG) and \( C_j = -C_j \) [21]. The use of identical gratings simplifies fabrication and as shown in (2) and (3), opposite orientations (or chirp rates) enables higher values of central frequency and RF chirp. With an all-fiber DFPC based on 10 mm long linearly chirped fiber Bragg gratings having identical grating chrips \( |C_j| = |C_j| = C = 0.1 \text{ nm/mm} \) and \( L_{\text{offset}} = 12 \text{ mm} \), linearly chirped microwave waveforms with \( f_c = 15 \text{ GHz} \), an RF chirp = 0.0217 GHz/ps, and a TBWP = 37.5 (with corresponding pulse compression ratio of 62.5) were generated using 58 km of single mode fiber (SMF) for WTM.

![Fig. 3. Schematic of the on-chip DFPC spectral shaper in SOI along with the waveguide cross-section.](image)

We implemented the DFPC design in SOI using parameters and processes typical of silicon photonic multi-project wafer runs (our devices were fabricated at the University of Washington Nanofabrication Facility using electron beam lithography with a single full etch) [22]. The DFPC (see Fig. 3) employs silicon nanowire waveguides with a cross-section of \( h \times W = 220 \times 500 \text{ nm} \) (the waveguides support the fundamental TE-like mode only); they sit on a 3 \( \mu \text{m} \) buried oxide (BOX) layer and have a 2 \( \mu \text{m} \) thick index-matched top oxide cladding. As with the all-fiber DFPC demonstrated in [21], we use two identical linearly chirped BGs with opposite orientation that are separated spatially by a length \( L_{\text{offset}} \). Of the different possible approaches to realize BGs, we have opted to use sidewall corrugations with a corrugation depth \( \Delta W \) directly in the nanowire waveguides [23-24]. The chirp is obtained by using a constant grating period and tapering the waveguide width [25], which is more robust compared to varying the grating period. Each BG has a grating period \( \Lambda = 315 \text{ nm} \), a corrugation depth \( \Delta W = 10 \text{ nm} \), and 500 periods (the corresponding grating length is \( L_g = 157.5 \text{ \mu m} \)). The waveguide width \( W \) increases linearly from 500 nm to 520 nm (or from 520 nm to 500 nm) from one end of the grating to the other and the estimated grating chirp is \( |C_j| = |C_j| = C = 12.2 \text{ \mu m/mm} \).

For spectral shaping, we use the reflection response of the DFPC, which is extracted via a Y-branch splitter [23]. Vertical grating couplers (VGCs) are used for input and output coupling and are optimized for TE mode operation [23]. The total fiber-to-fiber insertion loss is 25 dB with each VGC contributing \( \sim 10 \text{ dB} \) loss. The total size of the on-chip spectral shaper is 720 \( \mu \text{m} \times 70 \mu \text{m} \).

Fig. 4 shows the measured reflection spectra of two on-chip DFPCs with \( L_{\text{offset}} = 307.5 \text{ \mu m} \) and 457.5 \( \mu \text{m} \). As expected from (1), the FSR at a specific wavelength is smaller when \( L_{\text{offset}} \) is larger and in both cases, the FSR increases with detuning from \( \lambda_0 \) (note that since we use \( C_j > 0 \), the equivalent cavity length decreases with increasing detuning from the starting wavelength \( \lambda_0 \) so that there is a corresponding increase in FSR).

![Fig. 4. Reflection spectra of on-chip DFPC spectral shaper in SOI with \( L_{\text{offset}} = 307.5 \text{ \mu m} \) (a) and 457.5 \( \mu \text{m} \) (b).](image)

To generate chirped microwave waveforms, we use a pulsed broadband source (femtosecond laser) and 5 km of SMF for WTM (an optical bandpass filter is used after the laser so that the broadband source spectrum matches the reflection bandwidth of the DFPCs). The results are summarized in Fig. 5: the values of \( f_R \) and RF chirp are 15 GHz and 0.011 GHz/ps, and 20 GHz and 0.012 GHz/ps for \( L_{\text{offset}} = 307.5 \text{ \mu m} \) and 457.5 \( \mu \text{m} \), respectively. As predicted by (2) and (3), increasing \( L_{\text{offset}} \) yields higher values of \( f_R \) without changing the RF chirp. The generated waveforms are \( \sim 1,100 \text{ ps} \) in duration and the estimated TBWPs are 13.3 and 14.5. The compressed pulses, which are obtained by calculating the autocorrelation of the measured waveforms, have full width at half maximum (FWHM) durations of 120 ps and 50 ps, corresponding to pulse compression ratios of 9 and 12.

![Fig. 5. Generating chirped microwave waveforms using on-chip DFPC spectral shaper in SOI. Temporal waveforms and instantaneous frequency vs. time (a,b) and calculated auto-correlation showing pulse compression (c,d) with \( L_{\text{offset}} = 307.5 \text{ \mu m} \) (left) 457.5 \( \mu \text{m} \) (right).](image)
C. Michelson Interferometer with Chirped Bragg Gratings

A simple means to create a filter with a periodic spectral response is to use a 3 dB coupler and two identical uniform period BGs to form a Michelson interferometer, see Fig. 6(a) [26]. An offset placed in one branch of the interferometer enables control of the interference of light being reflected back from the two gratings (and hence, the FSR of the resulting filter). To create an aperiodic spectral response, chirped BGs can be used. If this filter is used as a spectral shaper, the expressions for the wavelength dependent FSR, $f_{RF}$, and RF chirp of the generated waveforms are also given by (1) – (3) with $L_{offset}$ corresponding to the wavelength independent path difference created by the physical offset of the BGs in the interferometer arms and $\lambda_0$ being the center, rather than starting, wavelength (here, $L(\lambda)$ represents the length difference between the arms of the interferometer and includes the wavelength independent path difference/offset as well as the wavelength dependent length difference due to the grating chirp).

![Fig. 6. Spectral shaper based on a Michelson interferometer incorporating two chirped BGs: (a) general schematic and (b) on-chip implementation in SOI with chirped BGs having opposite orientation and perspective view of chirped BGs (courtesy of J. Yao).](image)

In contrast to the DFPC, it is easier to implement a wider range of values of $L_{offset}$ with the Michelson interferometer. While fully or partially superimposed fiber Bragg gratings can be fabricated readily to have $L_{offset} < L_g$ (due to the physical mechanism of photoinduced refractive index changes), it is more difficult to realize the corresponding ‘superimposed’ grating profiles with on-chip BGs based on sidewall corrugations. For $L_{offset} = 0$, the spectral response is symmetric about $\lambda_0$ and the FSR decreases with increasing detuning (i.e., the largest value of FSR is obtained at $\lambda_0$). For a sufficiently large offset, the spectral response is no longer symmetric and there is a monotonic increase or decrease in FSR.

Zhang and Yao recently demonstrated an on-chip version of the Michelson interferometer incorporating oppositely chirped gratings in SOI as shown in Fig. 6(b) [27]. Silicon nanowire waveguides are used for all passive interconnections and the Y-branches. On the other hand, a rib waveguide is used for the BGs. The gratings use sidewall corrugations on the slab and the chirp is obtained by tapering the rib width. The BGs have a length $L_g = 12.54$ mm, a nominal chirp of 0.88 mm/m, and span a wavelength range from 1538 nm to 1544 nm. Using a length of dispersion compensating fiber with a dispersion of -1700 ps/nm for WTM, the corresponding generated chirped microwave waveforms for two spectral shapers with $L_{offset} = 0$ and $L_{offset} = L_g$ are shown in Fig. 7. For $L_{offset} = 0$, the spectral response is symmetric about the center wavelength whereas the FSR increases monotonically with wavelength when $L_{offset} = L_g$. For the latter device, the generated chirped microwave waveform has $f_{RF} = 15.4$ GHz, an RF chirp = 0.00154 GHz/ps, and a TBWP = 615 (with a pulse compression ratio as high as 623).

D. Sagnac Loop

One possible drawback of the spectral shaper based on the Michelson interferometer is the need for two identical BGs. Instead, a single grating can be used in a Sagnac interferometer as illustrated in Fig. 8 [28]. The wavelength independent offset is controlled by the path mismatch, i.e., $L_{offset} = L_1 - L_2$. With a single chirped grating, the Sagnac loop provides the same functionality as the Michelson interferometer with two identical and oppositely chirped BGs. As such, the wavelength dependent FSR, $f_{RF}$, and RF chirp are again given by (1) – (3) ($L(\lambda)$ has the same interpretation as in the case of the Michelson interferometer).

Wang and Yao developed an all-fiber version of this spectral shaper using a 10 mm long linearly chirped fiber Bragg grating with a grating chirp $C = 2$ nm/cm [29]. They included a tunable ODL in one path to vary $L_{offset}$ (e.g., to have either a monotonic increase or decrease in FSR). As a proof-of-principle demonstration, they used 30.8 km of SMF for WTM and generated linearly chirped microwave waveforms with $f_{RF} = 20.2$ GHz (24.5 GHz), RF chirps of 0.02 GHz/ps (-0.022 GHz/ps), and TBWP = 44.8 (41) with corresponding pulse compression ratios of 54.7 (56.5).

![Fig. 7. Generating chirped microwave waveforms using on-chip spectral shaper based on a Michelson interferometer incorporating two oppositely chirped BGs in SOI. (a) Spectral response, (b) temporal waveform (top), instantaneous frequency (middle), and calculated compressed pulse (bottom) for $L_{offset} = 0$ (left) and $L_g$ (right) (courtesy of J. Yao).](image)
We have implemented the Sagnac loop based spectral shaper in SOI using the same platform and fabrication processes as with the on-chip DFPCs [30]. As before, we use nanowire waveguides with a cross-section of $h \times W = 220 \text{ nm} \times 500 \text{ nm}$. 3 dB coupling is provided by a multi-mode interference (MMI) coupler; it is 6 $\mu$m wide by 127 $\mu$m long and the input and output nanowire waveguides are separated by 3 $\mu$m to avoid additional coupling. The BG has a uniform period ($\Lambda = 320 \text{ nm}$) and sidewall corrugations $\Delta W = 10 \text{ nm}$; the chirp is obtained by varying linearly the waveguide width from 500 $\text{nm}$ to 510 $\text{nm}$ from one end of the grating to the other (the estimated grating chirp is $C \approx 0.26 \text{ nm/mm}$). The grating comprises 10,000 periods for a total length $L_g = 3.2 \text{ mm}$. Due to the different waveguide widths at one end of the chirped grating and the input/output of the MMI coupler, we employ a 10 $\mu$m long taper to bring the waveguide width at the wide end of the grating from 510 $\text{nm}$ back to 500 $\text{nm}$.

Fig. 9 shows the spectral responses for two on-chip Sagnac loop spectral shapers with $L_{\text{offset}} = 100 \mu$m and 400 $\mu$m. These values of path mismatch are insufficient to induce a monotonic increase or decrease in FSR over the grating bandwidth ($\sim 12 \text{ nm}$), i.e., the spectral response is still somewhat symmetric about the center wavelength $\lambda_0$ and the FSR decreases with increasing detuning away from $\lambda_0$. However, by tuning the center wavelength of a pulsed broadband source with a bandwidth that is smaller than the grating bandwidth, we can generate chirped microwave waveforms having different $f_{RF}$ and/or RF chirp of opposite sign.

As a demonstration, we use an optical bandpass filter to reduce the FWHM bandwidth of our pulsed broadband source to 1.5 $\text{nm}$ and tune its center wavelength to various portions of the grating response as shown in Fig. 9; we also use 24 $\text{km}$ of SMF for WTM. The results are summarized in Fig. 10: a central frequency of up to 30 GHz can be obtained with an RF chirp of $\pm 0.02 \text{ GHz/ps}$. Fig. 11 illustrates typical chirped microwave waveforms and the TBWPs are between 15 and 20.

Fig. 11. Temporal waveform and instantaneous frequency vs. time for chirped microwave waveform generated using an on-chip spectral shaper based on a Sagnac loop incorporating a chirped BG with $L_{\text{offset}} = 100 \mu$m and a detuning of -4 $\text{nm}$ (a) and 4 $\text{nm}$ (b) between the central wavelength of the pulsed broadband source and the spectral shaper response.

E. Discussion

Table 1 compares the on-chip spectral shapers based on BGs in SOI for generating chirped microwave waveforms, particularly with respect to RF chirp and TBWP. Results from all-fiber implementations, where available, are also included. The TBWP depends on the grating chirp $C$ and the bandwidth

![Fig. 8. Schematic of a spectral shaper based on a Sagnac loop incorporating a linearly chirped BG.](image)

![Fig. 9. Spectral responses of on-chip spectral shaper based on a Sagnac loop incorporating a chirped BG with $L_{\text{offset}} = 100 \mu$m (a) and 400 $\mu$m (b). The normalized spectra of the broadband pulses used for generating chirped microwave waveforms are also shown (red).](image)

![Fig. 10. Characteristics of chirped microwave waveform generated using an on-chip spectral shaper based on a Sagnac loop incorporating a chirped BG. (a) $f_{RF}$ and (b) RF chirp as a function of detuning between the center wavelength of the pulsed broadband source and the spectral shaper response (for the measured points, the corresponding overlap between the pulsed broadband source and spectral shaper response are shown in Fig. 9).](image)
of the spectral shaper (denoted $B_\alpha$) [27,29]:

$$TBWP \propto \frac{B_\alpha^2}{C}$$

(4)

or equivalently,

$$TBWP \propto CL_g$$

(5)

since $B_\alpha$ is directly proportional to $C$ and $L_g$. Achieving a higher TBWP requires an increase in the grating chirp $C$ and/or the grating length $L_g$ (note that $B_\alpha$ is constrained by the requirement for a linear WTM, e.g., it must be constrained so that higher-order dispersion in the dispersive medium used to implement WTM can be neglected). For the on-chip spectral shaper based on a Sagnac loop incorporating a chirped BG described in Section 2D, a maximum TBWP of 233 is possible based on the chirped grating characteristics. However, in the experiments, since the bandwidth of the pulsed broadband optical source was restricted to 1.5 nm to provide tunability, only a fraction of the spectral shaper bandwidth was used ($B_\alpha = 1.5$ nm), giving rise to the demonstrated TBWPs of 15 - 20 only. While longer grating lengths are more readily available in fiber compared to waveguides in SOI, the TBWP of on-chip configurations can provide greater TBWPs compared to their all-fiber counterparts.

**TABLE I**

**Comparison of RF chirp and TBWP of chirped microwave waveforms generated using on-chip and all-fiber spectral shapers based on BGs and MRRs**

<table>
<thead>
<tr>
<th>BG</th>
<th>On-chip in SOI</th>
<th>All-fiber</th>
</tr>
</thead>
<tbody>
<tr>
<td></td>
<td>RF chirp (GHz/ps)</td>
<td>TBWP</td>
</tr>
<tr>
<td>DFPC</td>
<td>0.011</td>
<td>9-12</td>
</tr>
<tr>
<td>Michelson</td>
<td>0.0154</td>
<td>615</td>
</tr>
<tr>
<td>Sagnac</td>
<td>0.02</td>
<td>15-20</td>
</tr>
<tr>
<td>MRR add/drop</td>
<td>0.011</td>
<td>6.5</td>
</tr>
<tr>
<td>MZI</td>
<td>0.017</td>
<td>~20</td>
</tr>
</tbody>
</table>

In addition to BGs, on-chip spectral shapers with an aperiodic filter response (i.e., variable FSR) can be realized by cascading multiple MRRs having different resonant wavelengths. For example, Khan et al. cascaded 8 MRRs, each with an FSR of ~16 nm and a wavelength separation of ~1.3 nm between consecutive rings, in a conventional add/drop configuration in SOI [31]. Within the 16 nm FSR, 8 wavelengths were ‘dropped’ from a pulsed broadband optical source (corresponding to 8 time domain ‘cycles’ after WTM); chirped microwave waveforms with $f_{RF} \sim 10$ GHz and an RF chirp $\sim 0.01$ GHz/ps were obtained. As a second example, Zhang and Yao used 5 cascaded MRRs in a Mach-Zehnder interferometer (MZI) to generate chirped microwave waveforms with $f_{RF} = 15.5$ GHz and an RF chirp = 0.017 GHz/ps [10]. One advantage of this configuration is that the input and output share a common coupling port which will increase robustness and tolerance to fabrication errors, especially when VGCs are used. While MRRs are suitable for high-density integration and support greater compactness compared to BGs, the limited number of MRRs that can be cascaded will, in turn, limit the achievable TBWP.

Other passive optical pulse shaping techniques as well as active systems have been investigated for generating chirped microwave and millimeter wave waveforms. Of particular note are interferometric spectral shapers which have been implemented in-fiber [32] or with free space optics [33]. With the latter, Rashidinejad and Weiner generated chirped microwave waveforms spanning the 70 - 110 GHz frequency range with a TBWP as large as 600 for high resolution W-band ranging applications [34]. Additionally, chirped waveforms with a record-high TBWP of up to 70,000 have been realized by heterodyne beating of a continuous wave and wavelength-swept laser (or pre-chirped pulse) [35].

While on-chip spectral shapers may not match the performance of active systems, they offer several interesting features. First, by introducing a pn junction to the silicon waveguide and applying a bias voltage, reconfiguration can be enabled through the plasma dispersion effect. In particular, if the junction is introduced along the rib waveguide BG, the grating chirp, and hence RF chirp and TBWP, can be tuned. Indeed, this approach was adopted by Zhang and Yao to realize electrical tuning of the on-chip spectral shaper based on a Michelson interferometer incorporating chirped BGs; the generated chirped microwave waveforms had TBWPs ranging from 95 to 143 [36]. On the other hand, tuning the wavelength independent offset $L_{offset}$ may be possible if the junction is introduced in the offset waveguide; this will allow for control over $f_{RF}$.

Fig. 12. Design concept for multi-carrier chirped waveforms using on-chip spectral shapers based on (a) parallel DFPCs and (b) arrayed waveguide Sagnac interferometer incorporating chirped BGs.
Second, we can exploit the parallelism of optics to generate multiple chirped microwave waveforms with different characteristics ($f_{RF}$ and RF chirp) simultaneously using a single device structure. For example, as shown in Fig. 12(a), DFPCs can be designed to occupy separate spectral bands and arranged in parallel to generate wavelength-division-multiplexed (WDM) waveforms. Recently, high-performance arrayed waveguide gratings (AWGs) in SOI have been realized [37,38]. Thus, a second alternative to obtain WDM chirped waveforms is to incorporate chirped BGs in an arrayed waveguide Sagnac interferometer [39]. This latter implementation exhibits greater flexibility for reconfiguration via tuning the BG or $L_{offset}$. The WDM nature of the generated waveforms may provide enhanced capabilities for radar, ranging, and instrumentation applications.

III. OPTICAL TRUE-TIME DELAY LINES

A. General Overview

An ODL is a fundamental building block that enables numerous signal processing functions in MWP systems and applications [40,41]. For example, they are used to develop MWP filters and devices to control phase shift. ODLs are also important for beamforming in phased array antennas, especially to avoid beam squint which can arise when using electronic delay lines [42-45]. Characteristics of ODLs include, amongst others, large delay, small incremental delay steps (especially for beamforming as the operating frequency of the antenna system increases) or continuous delay, broad operating bandwidth, and low loss. Note that the specific features that an ODL is required to provide are application-specific and not all are required simultaneously.

There are a number of ways to implement an optical delay passively, i.e., without gain, and these can be broken down in two broad approaches: (1) variation of the propagation length ($L$) of the delay element (i.e., the delay $\Delta t$ is given by $L/v_g$ where $v_g$ is the propagation group velocity), also known as a length variable delay line [43-49] and (2) variation of the propagation group velocity ($v_g$), also referred to as a variable propagation velocity line and for some implementations, a wavelength variable delay line [50-59]. These two approaches encompass employing a fixed length of waveguide, fiber, or free space as the delay medium, as well as resonance enhancements, whereby the physical length of the delay medium is enhanced, e.g., through a cavity or exploiting a material resonance where dispersion can be large. The use of resonance enhancements is appealing and indeed, optical filters based on cascaded MRRs, which are all-pass filters having large delay on resonance and a unity magnitude response, have been used to develop continuously tunable delays (see, e.g., [7,51-53]). However, there is a well-known trade-off between the amount of resonance enhancement that can be obtained and the operating bandwidth [60]. In this paper, we focus on ODLs that do not involve resonance enhancements. Integrated ODLs are more compact, provide greater temporal resolution, and greater stability compared to fiber or micro-electro-mechanical-systems.

A wavelength variable ODL can be implemented using a highly dispersive waveguide to create group velocity variation among different wavelengths ($\lambda$), see Fig. 13(a). In this case, optical pulses or signals need to be carried on different wavelengths (or carrier frequencies), e.g., $\lambda_1$, $\lambda_2$, etc., to experience different propagation velocities and correspondingly, different propagation time delays, see Fig. 13(d). Integrated wavelength variable ODLs have been demonstrated using photonic crystal waveguides and Bragg gratings. For example, in SOI, a variable delay of several hundred picoseconds over an optical bandwidth of a few nm’s can be obtained with chirped waveguide BGs [25] while a (nonlinear) delay of up to 70 ps over 20 nm was obtained with a photonic crystal waveguide [57]. While such ODLs are important as sampled delay lines for MWP filters, they cannot be used in applications where the time delays must be obtained at the same wavelength.

Fig. 13. Illustration of the conventional approach for wavelength-variable ODL (a), the conventional approach for length-variable OTTDL (b), and our proposed approach of index-variable OTTDL (c). Two comparisons between these approaches are illustrated in the plot of $v_g$ vs. $\lambda$ in (d).

An ODL providing time delays for pulses/signals having the same optical carrier/wavelength is one form of an optical true time delay line (OTTDL). The conventional architecture of such a length variable OTTDL is depicted in Fig. 13(b) where the (incremental) time delay between adjacent waveguides (also referred to as taps) is obtained by changing the length of each waveguide. Note that for (discretely) tunable OTTDLs, the different lengths of waveguides are commonly interconnected via $2 \times 2$ or $1 \times N/N \times 1$ switches.
(or splitters/combiners). To minimize chip size, such delay architectures generally involve waveguides with curvy or spiral/serpentine topologies. Impressive results have been demonstrated in both SOI and silicon nitride. For example, a 7 bit (discretely tunable) delay with a maximum delay of 1.27 ns delay and 10 ps resolution (step size) based on 8 cascaded 2 × 2 MZI switches and 7 waveguide paths in SOI was reported [49]. The minimum delay path in each stage of the device was 4 mm and incremental path differences in integer multiples of 808 μm were used. Ridge waveguides with a wide waveguide width of 3 μm were considered to reduce sidewall scattering loss. The waveguides were arranged in a serpentine manner and the total chip size was 7.4 mm × 1.6 mm. For a signal experiencing the maximum delay, the insertion loss was 11 dB. Phase measurements confirmed a maximum delay of ~ 1.3 ns for RF frequencies up to at least ~ 25 GHz. With silicon nitride, a 4 bit discretely tunable delay with a maximum delay of 12.35 ns and 850 ps resolution (step size) based on 5 cascaded 2 × 2 MZI switches and 4 waveguide paths was reported [48]. In this case, the longest delay path involved a waveguide length of 1.284 m in a spiral configuration with < 5 mm bend radii and propagation losses of ~ 1 dB/m. The device is compact, occupying a total chip size of ~ 4.5 × 8.5 cm.

One approach to minimize or reduce complexities with curvy or spiral/serpentine topologies in length variable OTTDLs is to develop an index variable OTTDL where true time delay control is realized through varying the group index/propagation velocity in the waveguides. Note that the ODL structure illustrated in Fig. 13(a) is not an OTTDL that provides time delays for signals at the same wavelength since the variable index/propagation velocity controls the relative wavelength dependent delay and not the true time delay. Recently, Gasulla and Capmany proposed to exploit the parallelism inherent in multicore fibers to implement a sampled true time delay line for MWP applications [61]: the use of a heterogeneous multicore fiber design provides a different delay for a given optical carrier at the output of each fiber (the time delay is controlled through designing a proper physical dimension and material doping concentration of each fiber core). By tailoring an independent dispersion profile per core, a differential/incremental delay between taps of a few ps/km can be achieved [62]. We now describe an approach to realize an integrated version of this OTTDL concept.

B. SWG waveguides for OTTDLs

Recently, there has been growing interest in SWG structures for developing integrated optical components [63-66]. SWGs are formed by a periodic arrangement (with period Λ) of high refractive index material (e.g., silicon) with a thickness a implanted into a low refractive index material (e.g., silica); the duty cycle of the SWG is defined as D = a/Λ, see Fig. 14(a). Efficient fiber-to-chip surface grating couplers in SOI based on crosswise operation, where light propagates perpendicularly to the subwavelength structure, have been reported [65,66]. Light can also propagate along the axis of the subwavelength structure, i.e., lengthwise operation, giving rise to the notion of SWG waveguiding.

To create an SWG waveguide, finite transverse dimensions, e.g., a height h and width W, are applied to the material of high refractive index. Light propagation along the axis of the subwavelength structure (periodic refractive index arrangement) can be understood in a similar manner to electron propagation in a periodic potential and can be described using Bloch waves. The operating regime of the SWG waveguide depends on the carrier frequency of the incident light signal. At low frequencies, the propagation constant increases with frequency as in a conventional waveguide, i.e., the subwavelength regime. At higher frequencies, Bragg reflection occurs and light is reflected back, i.e., the Bragg reflection regime. At even higher frequencies above this bandgap lies the radiation regime where the Bloch mode becomes leaky and light is scattered out of the waveguide, i.e., the radiation regime. We are particularly interested in the first operating regime—the subwavelength regime—where light perceives the periodic structure as an effective medium. In other words, the SWG waveguide can be modeled as a conventional nanowire waveguide having the same transverse dimensions and a uniform refractive (effective) index along the direction of propagation.

The important parameter of the SWG waveguide is the effective index n, which depends on the duty cycle D [66]:

\[
n = \sqrt{Dn_1^2 + (1-D)n_2^2}
\]

where n₁ and n₂ are the effective refractive indices of the silicon and silica waveguides, respectively. The group index of the SWG waveguide (n_g) can be calculated from the well-known definition

\[
n_g = n + \omega \frac{dn}{d\omega},
\]

where \(\omega\) is the optical frequency. Substituting (6) in (7) gives

\[
n_g = \frac{n_1n_{g1}D + n_2n_{g2}(1-D)}{\sqrt{Dn_1^2 + (1-D)n_2^2}}.
\]

where \(n_{g1}\) and \(n_{g2}\) are the group indices of the silicon and silica waveguides as defined by (7).

In addition to SWG waveguides (with propagation losses of ~ 2 - 3 dB/cm), a number of SWG waveguide devices have been demonstrated, such as directional and MMI couplers,
waveguide crossings, bends, Bragg gratings, and ring resonators [63-70]. Moreover, the use of SWG waveguides to create a delay/path length mismatch in an MZI was demonstrated recently [71]. We build on this idea and take advantage of the ability to tune the effective index of an SWG waveguide through control of its duty cycle \( D \) to realize an integrated index variable OTTDL [72].

\[ D = 1\% \text{, } 2\% \text{, and } 3\% \]

The measured FSR from each MZI of the two SWG waveguides as depicted in Fig. 15(a) [the same fabrication processes for developing the on-chip spectral shapers in SOI are used]. The measured FSR from each MZI can then be correlated with the optical delay/path length mismatch induced by \( \Delta D \). The SWG waveguides have a cross-section of \( h \times W = 220 \text{ nm} \times 500 \text{ nm} \); as with the on-chip spectral shapers, they sit on a 3 \( \mu \text{m} \) BOX layer and are covered by a 2 \( \mu \text{m} \) thick index-matched top oxide cladding. The SWG waveguides are coupled to conventional silicon nanowires using a taper which converts a mode propagating in a silicon nanowire waveguide into a Bloch mode that propagates in the SWG waveguide. The tapers are based on a linearly chirped waveguide grating implemented with a uniform grating period \( P \) and where the waveguide width is narrowed linearly from \( W_1 \) to \( W_2 \) over a length \( L_{taper} \) as illustrated in Fig. 14(c) [67]. In our devices, we use \( P = 200 \text{ nm} \) and the waveguide width is varied from 500 nm down to 200 nm over a length of \( L_{taper} = 15 \text{ \mu m} \). Two conventional Y-branches are used to form the MZI and VGCs optimized for TE polarization provide input and output coupling (the Y-branches and VGCs have the same design as those used for the on-chip spectral shapers). The SWG waveguides have a period \( \Lambda = 250 \text{ nm} \) and the same length of 8 mm. Fig. 15(b) shows the measured spectral responses of 3 MZIs with \( \Delta D = 1\% \text{, } 2\% \text{, and } 3\% \); the FSRs are \( \sim 5 \text{ nm} \), \( \sim 2.9 \text{ nm} \), and \( \sim 1.7 \text{ nm} \), respectively, corresponding to delay differences of 1.6 ps, 2.8 ps, and 4.7 ps between the MZI arms. These results demonstrate that an incremental time delay of a few picoseconds can be obtained readily between SWG waveguides of the same length using a small difference in duty cycle. Of course, the minimum incremental time delay will scale proportionally with the SWG waveguide length; as such, sub-picosecond delays are expected with shorter waveguides (< 8 mm).

Next, we fabricated an array of SWG waveguides which can provide optical true time delay for microwave phase shifting, see Fig. 16(a). The SWG waveguides, tapers, and VGCs are the same as those used in the MZIs. By using a different duty cycle for each SWG waveguide, different optical paths among the waveguides which have the same length can be engineered to control the incremental time delay. The 4 SWG waveguides are all 8 mm long and their effective indices are varied in 10% increments from 30% to 60% to provide an incremental time delay of \( \sim 10 \text{ ps} \).

![Fig. 15](image1)

**Fig. 15.** (a) Schematic of MZI incorporating SWG waveguides with different duty cycles \( D_1 \) and \( D_2 \) in each arm. (b) Measured spectral responses of MZIs with three different values of \( \Delta D \).

![Fig. 16](image2)

**Fig. 16.** (a) Schematic of OTTDL based on an array of 4 SWG waveguides and experimental setup for microwave phase shift measurements. (b) Measured RF phase shift vs. modulation frequency for an optical carrier at 1565 nm.

A vector network analyzer (VNA) is used to measure the RF phase shift as a function of frequency as depicted in Fig. 16(a). Fig. 16(b) shows the measured RF phase shift as a function of RF frequency for the 4 waveguides at an optical carrier wavelength of 1565 nm. The time delay of each waveguide can be obtained from the average slope of the phase shift. From the measurements, we estimate incremental time delays of 8.9 ps, 10.7 ps, and 7.9 ps between the SWG
waveguides with $D_1 = 60\%$, $D_2 = 50\%$, $D_3 = 40\%$, and $D_4 = 30\%$, respectively. The simulated effective and group indices of silicon and silica for our waveguide dimension at a wavelength of ~1560 nm are $n_1 = 2.4$, $n_{g1} = 4.4$, $n_2 = 1.45$, and $n_{g2} = 1.47$. According to (8), the group indices of the SWG waveguides for $D = 60\%$, $50\%$, $40\%$, and $30\%$ are $n_g = 3.47$, $3.2$, $2.91$, and $2.61$, respectively, and the corresponding wavelength of ~1560 nm are 30%, respectively. The simulated effective and group indices of the VGCs, (2) propagation loss in the SWG waveguide, and (3) loss due to mode mismatch between the nanowire waveguide and SWG waveguide. The mode mismatch is more pronounced for SWG waveguides with smaller values of duty cycle $D$ (it is also polarization dependent though this is not problematic in our case since the VGCs are optimized for operation on a single polarization only) [67]. While tapers can reduce mode mismatch, a taper loss still exists. Moreover, each duty cycle requires its own optimal taper design to reduce loss due to mode mismatch. In our proof-of-principle demonstration, we used the same taper design for all 4 SWG waveguides; as such, the total fiber-to-fiber loss between them is not the same and the loss is highest for the waveguide with $D = 30\%$ (it is several dB higher than for the waveguide with $D = 60\%$) [70]. More generally, if we choose to use the same taper design for simplicity, then minimizing the variation in fiber-to-fiber loss among the different SWG waveguides will require the use of smaller differences in duty cycle.

The minimum incremental time delay and the maximum time delay that can be obtained depend on the minimum and maximum differences in duty cycle that can be used. For example, with a difference in duty cycle of $\Delta D = 1\%$, an incremental time delay of 1.6 ps can be obtained with 8 mm long SWG waveguides whereas with a difference in duty cycle of $\Delta D = 30\%$, the incremental delay increases to 27.5 ps. Reducing the incremental time delay can be achieved readily by reducing the length of the SWG waveguides and sub-picosecond values are possible. On the other hand, increasing the maximum delay (and/or the maximum incremental delay) will require substantial increases in SWG waveguide length. It is possible to arrange the SWG waveguides in a serpentine manner to increase the total length while maintaining a compact size. For example, a 90° bending loss of ~1.5 dB was demonstrated for a bend radius of 10 μm; this loss was reduced to ~1 dB when the bend radius was increased to 30 μm. These losses can be reduced even further by utilizing trapezoidal silicon segments (as opposed to rectangular silicon segments) in the SWG waveguide bends [73]. As mentioned previously, the typical propagation losses in SWG waveguides are similar to those in silicon nanowire waveguides [63,64]. Thus, SWG waveguides should support not only small incremental delays (for high resolution) but also maximum delays of a few nanoseconds (similar to those reported in [49] which are based on silicon rib waveguides).

The index variable design allows the different taps of the OTTDL to be realized in a compact array of straight waveguides with identical lengths. Note that as with any OTTDL design, the SWG waveguides must be separated by a sufficient distance to avoid coupling (especially for a serpentine arrangement as SWG waveguides with the same duty cycle are placed in close proximity). The separation depends on duty cycle as stronger coupling has been observed for SWG waveguides with smaller values of $D$ [67].

It should be noted that to implement a discretely tunable OTTDL, 2 × 2 switches are required. SWG waveguide-based switches or modulators have yet to be demonstrated although all of the components exist for their implementation. On the other hand, it is possible to use a conventional silicon 2 × 2 MZI switches, i.e., the SWG waveguides are exploited only for developing the index variable delay elements whereas conventional silicon waveguides are used for other components in the tunable OTTDL device.

The features that an ODL are required to provide will have a strong influence on the implementation. For example, while SWG waveguides can support both large as well as small total or incremental delays, continuous tuning will be more challenging to achieve. On the other hand, wavelength variable ODLs, including the use of resonance enhancements based on coupled resonators [7,50,51,53] or slow light effects in photonic crystal waveguides [52,57] or the dispersive properties of grating structures [55,56] (all in SOI) allow readily for continuous tuning. The tuning range, however, is typically limited from tens to ~200 ps. While the delays can be obtained in very compact structures (e.g., in [52], photonic crystal waveguides with lengths from 280 μm to 400 μm are considered while in [57], the length is 1.5 mm), the total insertion loss of the devices can be high (from 16 dB in [57] to 30 dB in [52]). It should be noted that a significant fraction of the loss tends to be associated with fiber coupling. For larger delays and discretely tunable delays, length variable and index variable ODLs will likely be preferred. At present, the fiber-to-fiber loss of SWG waveguide devices (including tapers and VGCs) tends to be higher compared to tunable devices demonstrated in silicon nitride [48] and SOI [49]. Further improvements in SWG waveguide device design as well as fabrication are required to make them more competitive with SOI structures.

IV. SUMMARY AND OUTLOOK

We have reviewed recent developments of integrated microwave photonic subsystems in SOI for generating chirped microwave waveforms and providing optical true time delay. The design and realization of on-chip spectral shapers based on BGs (particularly a DFPC, a Michelson interferometer incorporating identical chirped BGs, and a Sagnac loop incorporating a single chirped BG) to enable waveform generation via spectral shaping and WTM was discussed. These on-chip spectral shapers can be used to synthesize chirped microwave waveforms with an RF chirp and TBWP s that are comparable with all-fiber or free-space approaches; moreover, they outperform those based on MRRs. While this passive spectral shaping approach cannot generate similar TBWPs to those available from heterodyne beating, the value-added with on-chip spectral shapers may lie in the tunability (e.g., using the plasma dispersion effect in pn junction
waveguides), compactness, and the feasibility to develop parallel structures for simultaneous generation of multiple chirped waveforms.

We also described how an index variable OTTDL can be implemented using SWG waveguides. In particular, the ability to tune the group index of an SWG waveguide by controlling its duty cycle provides a straightforward mechanism to create different propagation delays between waveguides of the same length. A difference in duty cycle of only 1% (which can be readily obtained with ebeam processing) results in an incremental delay of 1.6 ps for waveguides 8 mm in length; sub-picosecond incremental delays are thus possible with shorter waveguides. To increase the incremental delay and/or achieve larger total delays, a greater difference in duty cycle is required. However, using large differences will result in greater variations in fiber-to-fiber loss, unless the tapers are specifically optimized for each SWG waveguide. Alternatively, longer SWG waveguides can be employed. While the propagation loss in SWG waveguides in SOI is similar to that in silicon nanowire waveguides, they are significantly higher than that available with silicon nitride waveguides. As such, for applications requiring very long delays, e.g., exceeding several nanoseconds, silicon nitride may be the material platform of choice. Since SWG waveguides are based on the same technology and waveguide design as silicon nanowires, they are compatible with existing silicon photonic devices, e.g., switches, modulators, etc. As such, SWG waveguide enhance the available component toolbox for developing integrated microwave photonic subsystems in SOI. Finally, SWG waveguide crossings with low loss (0.1-0.2 dB) and low crosstalk (< -40 dB) have been demonstrated [64]. As such, they offer the promise for very high density integration.

The technological developments described in this paper, along with others in silicon photonics such as high performance modulators and detectors, point to the feasibility of more complex integrated microwave photonic (sub-)systems that can provide increased functionality and ultimately performance.

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